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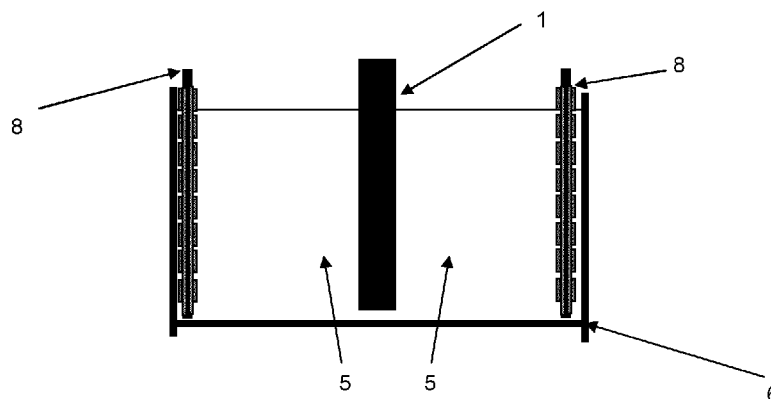
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(54) **Title:** DIRECT-CONTACT MEMBRANE ANODE FOR USE IN ELECTROLYSIS CELLS

Fig. 3



(57) **Abstract:** The present invention relates to an anode system for conventional electrolysis cells, a process for the production thereof and its use for the deposition of electrolytic coatings. The anode system is characterized in that the anode (2) is in direct contact with a membrane (3) which completely separates the anode space from the cathode space. This anode system is therefore a direct-contact membrane anode.

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